JCO3 Rec'd PCT/PTO 26 OCT 2007

NATIONAL PHASE UTILITY APPLICATION

Transmittal to the (DO/EO/US) Under 35 USC 371 Attorney Docket No.: SHIGA7.032APC First Named Inventor: Takuma Hojo

Int'l Application No.: PCT/JP2004/00580

Int'l Filing Date: April 22, 2004 Priority Date Claimed: April 30, 2003

Title: POSITIVE PHOTORESIST COMPOSITION AND METHOD FOR FORMING RESIST PATTERN

Express Mail Label No.: EV211991151US

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Date: October 26, 2005

Page 1 of 2

10/554380

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The following enclosures are transmitted herewith to be filed in the patent application of:

Inventors:

1. Takuma Hojo

2. Kiyoshi Ishikawa

3. Tsuyoshi Nakamura

4. Tasuku Matsumiya

APPLICATION ELEMENTS:

- (X) This is a FIRST submission of items concerning a filing under 35 U.S.C. § 371.
- (X) The U.S. has been elected (Article 31)... PEA 10/26/05
- (X) A copy of the International Application as filed (35 U.S.C. § 371(c)(2)) has been communicated by the International Bureau.
 - (X) PCT/IB/308 enclosed.
- (X) An English translation of the International Application as filed is attached hereto.
- (X) Amendments to the claims of the International Application under PCT Article 19 (35 U.S.C. § 371(c)(3)) have not been and will not be made.

OTHER APPLICATION PARTS:

- (X) Preliminary Amendment in 3 pages.
- (X) An Information Disclosure Statement and PTO/SB/08 equivalent listing references for consideration:
 - (X) Listing 14 references.
 - (X) Enclosing 10 references.
- (X) Cover page of PCT publication WO 2004/097526 A1.
- (X) International Search Report (PCT/ISA/210)
- (X) Written Opinion (PCT/ISA/237)
- (X) Return prepaid postcard.

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FILING FEES:

			F	EE (CALCU	JLATIO	ON		-				
FEE TYPE & DETERMINATION					LAR	GE FEE	CALCULATION			TOTAL			
Basic Filing Fee under 1.492(a)					1631	(\$300)			_		\$300		
Search Fee under 1.492(b) (e.	nter one	in T	OTAL	colu	mn)								
(1) USPTO was ISA and claims are novel					1640	(\$0)							
(2) USPTO was the ISA					1641	(\$100)					\$400		
(3) Foreign Search Report Enclosed 1642 (\$400)													
(4) No Search Report Enclosed 1632 (\$500)													
Examination Fee under 1.492(c) (enter one in TOTAL column)													
(1) USPTO was IPEA & claims satisfy Art. 33 (1)-(4)) 1643 (\$0)						(\$0)					\$200		
(2) Non US IPEA / Noncompliant Claims						1633	(\$200)						
Excess Claims	13	-	20	=	0	1615	(\$50)	0	х	50	=	\$0	
Excess Ind. Claims	1	-	3	=	0	1614	(\$200)	0	х	200	=	\$0	
Multiple Dep. Claim						1616	(\$360)					\$0	
Application Size Fee	0	-	100	=	0	1681	(\$250)	0	х	250	=	\$0	
Late English Translation						1618	(\$130)					\$0	
Assignment						8021	(\$40)	0	х	40	=	\$0	
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Intellectual Property Law

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Attorney Docket No.

SHIGA7.032APC

Applicant(s)

Hojo et al.

For

POSITIVE PHOTORESIST COMPOSITION

AND METHOD FOR FORMING RESIST

PATTERN

Attorney

Daniel E. Altman

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Date of Deposit

October 26, 2005

I hereby certify that the accompanying

Transmittal letter; English translation of specification in 32 pages; Preliminary Amendment in 3 pages; cover page of PCT publication; International Search Report and Written Opinion; PCT/IB/308; Information Disclosure Statement, PTO Form PTO/SB/08 Equivalent with 10 references; Check for Filing Fee; Return Prepaid Postcard

are being deposited with the United States Postal Service "Express Mail Post Office to Addressee" service under 37 CFR 1.10 on the date indicated above and are addressed to the Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450.

Nelson Merida

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